

# PROCEEDINGS OF SPIE

## ***Nanostructured Thin Films IV***

**Raúl J. Martín-Palma**  
**Yi-Jun Jen**  
**Tom G. Mackay**  
*Editors*

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# Contents

vii Conference Committee

---

## SESSION 1 OPENING SESSION

---

- 8104 02 **Green nanotechnology (Keynote Paper)** [8104-01]  
G. B. Smith, Univ. of Technology, Sydney (Australia)

---

## SESSION 2 PLASMONICS

---

- 8104 03 **Surface multiplasmonics** [8104-02]  
A. Lakhtakia, The Pennsylvania State Univ. (United States)
- 8104 05 **High-throughput nanofabrication of plasmonic structures and metamaterials with high resolution nanostencil lithography** [8104-04]  
S. Aksu, M. Huang, A. Artar, A. A. Yanik, H. Altug, Boston Univ. (United States)
- 8104 06 **Spatiotemporal-photothermal and photoacoustic conversions with local plasmon resonators (Best Student Paper Award)** [8104-05]  
K. Namura, M. Suzuki, K. Nakajima, K. Kimura, Kyoto Univ. (Japan)
- 8104 07 **Monitoring the reactivity of Ag nanoparticles for different atmospheres by using *in situ* and real-time optical spectroscopy** [8104-06]  
V. Antad, L. Simonot, D. Babonneau, S. Camelio, F. Pailloux, P. Guérin, CNRS, Institut Pprime, Univ. de Poitiers (France)

---

## SESSION 3 OPTICS

---

- 8104 09 **Nanostructure effects and the performance of optical interference coatings (Invited Paper)** [8104-08]  
O. Stenzel, U. Schulz, N. Kaiser, Fraunhofer Institute for Applied Optics and Precision Engineering (Germany)
- 8104 0A **Using a single anisotropic thin film as a phase retarder for oblique incident wave** [8104-09]  
Y.-J. Jen, S.-H. Wang, C.-F. Lin, M.-J. Lin, National Taipei Univ. of Technology (Taiwan)
- 8104 0B **Quenched transmission of light through ultrathin metal films (Invited Paper) (Best Paper Award)** [8104-10]  
S. Xiao, N. A. Mortensen, Technical Univ. of Denmark (Denmark)
- 8104 0C **Optical properties of UT-shaped plasmonic nanoaperture antennas** [8104-11]  
M. Turkmen, Erciyes Univ. (Turkey) and Boston Univ. (United States); S. Aksu, A. E. Çetin, A. A. Yanik, H. Altug, Boston Univ. (United States)

- 8104 0D **Optical birefringence in a bideposited symmetric nanorod arrays** [8104-12]  
Y.-J. Jen, C.-W. Yu, M.-J. Lin, C.-F. Lin, National Taipei Univ. of Technology (Taiwan)

---

**SESSION 4 HOMOGENIZATION STUDIES**

---

- 8104 0E **Effective properties of metamaterials (Invited Paper)** [8104-13]  
C. Rockstuhl, C. Menzel, T. Paul, E. Pshenay-Severin, M. Falkner, C. Helgert, A. Chipouline, T. Pertsch, Friedrich-Schiller-Univ. Jena (Germany); W. Śmigaj, J. Yang, Lab. Charles Fabry de l'Institut d'Optique, CNRS, Univ. Paris-Sud (France); P. Lalanne, Lab. Charles Fabry de l'Institut d'Optique, CNRS, Univ. Paris-Sud (France); and Lab. Photonique, Numériques et Nanosciences, CNRS, Institut d'Optique, Univ. Bordeaux (France); F. Lederer, Friedrich-Schiller-Univ. Jena (Germany)
- 8104 0F **On dipole emission from an infiltrated chiral sculptured thin film** [8104-14]  
S. S. Jamaian, The Univ. of Edinburgh (United Kingdom); T. G. Mackay, The Univ. of Edinburgh (United Kingdom) and The Pennsylvania State Univ. (United States)
- 8104 0G **Homogenization of metallic metamaterials and electrostatic resonances** [8104-15]  
D. Felbacq, Lab. Charles Coulomb, CNRS, Univ. Montpellier 2 (France); E. Kling, SAGEM (France)

---

**SESSION 5 APPLICATIONS**

---

- 8104 0L **Microspot surface enhanced fluorescence from sculptured thin films for control of antibody immobilization** [8104-20]  
A. Karabchevsky, Ben-Gurion Univ. of the Negev (Israel); C. Patzig, B. Rauschenbach, Leibniz-Institut für Oberflächenmodifizierung e.V. (Germany); I. Abdulhalim, Ben-Gurion Univ. of the Negev (Israel)

---

**SESSION 6 NANOSTRUCTURED POROUS SILICON**

---

- 8104 0M **Intimate effects of surface functionalization of porous silicon microcavities on biosensing performance (Invited Paper)** [8104-21]  
M. Martin, Lab. Charles Coulomb, CNRS, Univ. Montpellier 2 (France); L. Massif, E. Estephan, Lab. Charles Coulomb, CNRS, Univ. Montpellier 2 (France) and UFR Odontologie, Univ. Montpellier 1 (France); M.-b. Saab, T. Cloitre, Lab. Charles Coulomb, CNRS, Univ. Montpellier 2 (France); C. Larroque, CRLC Val d'Aurelle-Paul Lamarque, IRCM, Univ. Montpellier 1 (France); V. Agarwal, CIICAP, Univ. Autónoma del Estado de Morelos (Mexico); F. J. G. Cuisinier, UFR Odontologie, Univ. Montpellier 1 (France); G. Le Lay, CINaM - Ctr. Interdisciplinaire de Nanoscience de Marseille (France) and Univ. de Provence (France); C. Gergely, Lab. Charles Coulomb, CNRS, Univ. Montpellier 2 (France)
- 8104 0N **Infiltration of Fe<sub>3</sub>O<sub>4</sub>-nanoparticles into porous silicon with respect to magnetic interactions** [8104-22]  
P. Granitzer, K. Rumpf, Karl-Franzens-Univ. Graz (Austria); M. Reissner, G. Hilscher, Technische Univ. Wien (Austria); M. P. Morales, Consejo Superior de Investigaciones Científicas (Spain); P. Poelt, T. Uusimäki, M. Sezen, M. Albu, Technische Univ. Graz (Austria)

8104 0O **Controlled skeletal progenitor cell migration on nanostructured porous silicon/silicon micropatterns** [8104-23]  
V. Torres-Costa, V. Sánchez-Vaquero, A. Muñoz-Noval, L. González-Méndez, E. Punzón-Quijorna, D. Gallach-Pérez, M. Manso-Silván, G. Martínez-Muñoz, A. Climent-Font, J. P. García-Ruiz, R. J. Martín-Palma, Univ. Autónoma de Madrid (Spain)

8104 0Q **Investigation of the interfaces of a metal/porous silicon nanocomposite and its influence on the physical properties** [8104-25]  
K. Rumpf, P. Granitzer, Karl-Franzens-Univ. Graz (Austria); M. Reissner, G. Hilscher, Technische Univ. Wien (Austria); P. Poelt, M. Albu, Technische Univ. Graz (Austria)

---

**SESSION 7 FABRICATION AND CHARACTERIZATION I**

---

8104 0U **An investigation on magnetic responses in Ag-SiO<sub>2</sub>-Ag nanosandwich structures** [8104-29]  
Y.-J. Jen, J.-J. Jhou, C.-W. Yu, National Taipei Univ. of Technology (Taiwan)

---

**SESSION 8 FABRICATION AND CHARACTERIZATION II**

---

8104 0V **Sculptured thin films: nanorods, nanopipes, nanosmiles (Invited Paper)** [8104-30]  
D. Gall, Rensselaer Polytechnic Institute (United States)

8104 0W **Electrophoretic deposition of Cu-In composite nanoparticle thin films for fabrication of CuInSe<sub>2</sub> solar cells** [8104-31]  
W. Guo, K. Hagedorn, B. Liu, IMRA America, Inc. (United States)

8104 0X **X-ray absorption fine-structure and optical studies of AlZnO nano-thin films grown on sapphire by pulsed laser deposition** [8104-32]  
Y. R. Lan, National Taiwan Univ. (Taiwan); S.-P. Liu, National Chung Hsing Univ. (Taiwan); C. C. Wei, National Taiwan Univ. (Taiwan); Y.-C. Fu, National Chung Hsing Univ. (Taiwan); Y. R. Wu, National Taiwan Univ. (Taiwan); J. M. Chen, National Synchrotron Radiation Research Ctr. (Taiwan); R.-H. Horng, National Cheng Kung Univ. (Taiwan); D.-S. Wu, National Chung Hsing Univ. (Taiwan) and Daye Univ. (Taiwan); Z. C. Feng, National Taiwan Univ. (Taiwan)

---

**SESSION 9 FABRICATION AND CHARACTERIZATION III**

---

8104 0Z **Luminescent multifunctional biocellulose membranes (Invited Paper)** [8104-34]  
J. M. A. Caiut, Univ. de São Paulo (Brazil); H. S. Barud, M. V. Santos, Univ. Estadual de São Paulo (Brazil); U. L. Oliveira, J. F. S. Menezes, Univ. Federal da Bahia (Brazil); Y. Messaddeq, Univ. Estadual de São Paulo (Brazil) and Univ. Laval (Canada); S. J. L. Ribeiro, Univ. Estadual de São Paulo (Brazil)

8104 10 **Chromogenic behaviours of silver containing mesoporous titania films** [8104-36]  
L. Nadar, N. Destouches, N. Crespo-Monteiro, F. Vocanson, Y. Lefkir, S. Reynaud, Univ. Lyon (France) and Lab. Hubert Curien, CNRS, Univ. Jean Monnet Saint-Etienne (France)

- 8104 11 **Electron microscopy characterization of some carbon based nanostructures with application in divertors coatings from fusion reactor** [8104-37]  
V. Ciupina, Univ. Ovidius Constanta (Romania); I. Morjan, C. P. Lungu, National Institute for Lasers, Plasma and Radiation Physics (Romania); R. Vladoiu, G. Prodan, M. Prodan, Univ. Ovidius Constanta (Romania); V. Zarovschi, C. Porosnicu, National Institute for Lasers, Plasma and Radiation Physics (Romania); I. M. Stanescu, M. Contulov, A. Mandes, V. Dinca, Univ. Ovidius Constanta (Romania); K. Sugiyama, Max-Planck-Institut für Plasmaphysik (Germany)
- 8104 12 **Optical investigation on plasmonic effect of the nanostructured surface plasmon resonance sensor chips fabricated by Langmuir-Blodgett technique** [8104-38]  
C. Yeon, S.-H. Sung, H.-S. Kim, J.-H. Kim, Ajou Univ. (Korea, Republic of)

---

#### POSTER SESSION

---

- 8104 15 **Tungsten nanostructured thin films obtained via HFCVD** [8104-42]  
O. Goiz, Ctr. de Investigacion y de Estudios Avanzados del IPN (Mexico); F. Chávez, P. Zaca-Morán, J. G. Ortega-Mendoza, G. F. Pérez-Sánchez, N. Morales, Benemérita Univ. Autónoma de Puebla (Mexico); C. Felipe, Ctr. Interdisciplinario de Investigaciones y Estudios sobre Medio Ambiente y Desarrollo (Mexico); R. Peña-Sierra, Ctr. de Investigacion y de Estudios Avanzados del IPN (Mexico)
- 8104 17 **Anisotropic optical property of an asymmetric bideposition Ta<sub>2</sub>O<sub>5</sub> film: fabrication and measurement** [8104-44]  
Y.-J. Jen, C.-F. Lin, T.-H. Yu, C.-J. Lai, National Taipei Univ. of Technology (Taiwan)

*Author Index*

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**Yiping Zhao**, The University of Georgia (United States)

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- 1 Opening Session  
**Raúl J. Martín-Palma**, Universidad Autónoma de Madrid (Spain)
- 2 Plasmonics  
**Tom G. Mackay**, The University of Edinburgh (United Kingdom)
- 3 Optics  
**Yi-Jun Jen**, National Taipei University of Technology (Taiwan)
- 4 Homogenization Studies  
**Hatice Altug**, Boston University (United States)
- 5 Applications  
**Akhlesh Lakhtakia**, The Pennsylvania State University (United States)
- 6 Nanostructured Porous Silicon  
**Motofumi Suzuki**, Kyoto University (Japan)

- 7 Fabrication and Characterization I  
**Raúl J. Martín-Palma**, Universidad Autónoma de Madrid (Spain)
- 8 Fabrication and Characterization II  
**Joseph V. Ryan**, Pacific Northwest National Laboratory (United States)
- 9 Fabrication and Characterization III  
**Daniel Gall**, Rensselaer Polytechnic Institute (United States)